Appl. No.: 09/844,947

Amdt. Dated: October 25, 2006 Reply to Office Action of: June 6, 2006

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The listing of claims will replace all prior versions, and listings, of claims in the application:

## Listing of Claims:

1. (currently amended) A method for producing a fused silica glass containing titania, comprising:

synthesizing particles of silica and litania by delivering a mixture of silica precursor and a titania precursor to a burner;

growing a column of solid porous preform by successively depositing the particles on a deposition surface at a temperature below a minimum temperature at which the particles can consolidate either partially or fully into dense glass while successively translating the deposition surface away from the burner; and

subsequently consolidating the porous preform into dense glass.

- 2. (previously presented) The method of claim 1, wherein a translation speed of the deposition surface is adjusted to maintain a substantially constant distance between an end portion of the porous preform remote from the deposition surface and the burner during deposition.
- 3. (cancelled)
- 4. (previously presented) The method of claim 1, wherein consolidating the porous preform into dense glass comprises heating the porous preform to a temperature in a range from 1200 to 1900°C.
- 5. (original) The method of claim 1, further comprising dehydrating the porous preform by exposing the porous preform to a heated, halide-containing atmosphere prior to consolidation.
- 6. (original) The method of claim 5, where in the heated, halide-containing atmosphere comprises chlorine.
- 7. (original) The method of claim 5, where in the heated, halide-containing atmosphere comprises fluorine.

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- 8. (original) The method of claim 5, wherein the temperature of the heated, halidecontaining atmosphere is in a range from 900 to 1100°C.
- 9. (original) The method of claim 1, wherein the glass contains 2 to 12% by weight titania.
- 10. 12 (previously cancelled)
- 13. (previously presented) The method of claim 5, wherein a translation speed of the deposition surface is adjusted to maintain a substantially constant distance between an end portion of the porous preform remote from the deposition surface and the burner during deposition.
- 14. (previously cancelled)
- 15. (previously presented) The method of claim 5, wherein consolidating the porous preform into dense glass comprises heating the porous preform to a temperature in a range from 1200 to 1900°C.
- 16. 19. (previously cancelled)
- 20. (previously presented) The method of claim 1, wherein the minimum temperature is approximately 1200°C.
- 21. (previously presented) The method of claim 20, wherein the temperature at which the particles are deposited is approximately 200 to 500°C less than the minimum temperature.
- 22. (cancelled)
- 23. (previously presented) The method of claim 1, wherein a variation on coefficient of thermal expansion of the dense glass is in a range from -5 ppb/°C to +5 ppb/°C.

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24. (previously presented) The method of claim 1, further comprising rotating the deposition surface relative to the burner while successively depositing the particles on the deposition surface.